

Astronomical Observing Techniques 2018

Lecture 9: Silicon Eyes 1

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Modern Detectors

Photon detectors

Responds to individual photons, releases electrons, X-rays to IR

Examples: photoconductors, photodiodes, photoemissive detectors

Thermal detectors

Absorbs photons, changes temperatures, changes resistance, IR and sub-mm detectors

Examples: bolometers

Coherent receivers

Responds directly to electrical field and preserve phase, mainly used in the sub-mm and radio regime

Examples: heterodyne receivers

PERIODIC TABLE OF THE ELEMENTS

<http://www.ktf-split.hr/periodni/en/>

GROUP	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18
PERIOD	1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16	17	18
1	1 1.0079 H HYDROGEN	2 4.0026 He HELIUM																
2	3 6.941 Li LITHIUM	4 9.0122 Be BERYLLIUM																
3	11 22.990 Na SODIUM	12 24.305 Mg MAGNESIUM																
4	19 39.098 K POTASSIUM	20 40.078 Ca CALCIUM	21 44.956 Sc SCANDIUM	22 47.867 Ti TITANIUM	23 50.942 V VANADIUM	24 51.996 Cr CHROMIUM	25 54.938 Mn MANGANESE	26 55.845 Fe IRON	27 58.933 Co COBALT	28 58.693 Ni NICKEL	29 63.546 Cu COPPER	30 65.39 Zn ZINC	31 69.723 Ga GALLIUM	32 72.64 Ge GERMANIUM	33 74.922 As ARSENIC	34 78.96 Se SELENIUM	35 79.904 Br BROMINE	36 83.80 Kr KRYPTON
5	37 85.468 Rb RUBIDIUM	38 87.62 Sr STRONTIUM	39 88.906 Y YTTRIUM	40 91.224 Zr ZIRCONIUM	41 92.906 Nb NIOBIUM	42 95.94 Mo MOLYBDENUM	43 (98) Tc TECHNETIUM	44 101.07 Ru RUTHENIUM	45 102.91 Rh RHODIUM	46 106.42 Pd PALLADIUM	47 107.87 Ag SILVER	48 112.41 Cd CADMIUM	49 114.82 In INDIUM	50 118.71 Sn TIN	51 121.76 Sb ANTIMONY	52 127.60 Te TELLURIUM	53 126.90 I IODINE	54 131.29 Xe XENON
6	55 132.91 Cs CAESIUM	56 137.33 Ba BARIUM	57-71 La-Lu Lanthanide	72 178.49 Hf HAFNIUM	73 180.95 Ta TANTALUM	74 183.84 W TUNGSTEN	75 186.21 Re RHENIUM	76 190.23 Os OSMIUM	77 192.22 Ir IRIDIUM	78 195.08 Pt PLATINUM	79 196.97 Au GOLD	80 200.59 Hg MERCURY	81 204.38 Tl THALLIUM	82 207.2 Pb LEAD	83 208.98 Bi BISMUTH	84 (209) Po POLONIUM	85 (210) At ASTATINE	86 (222) Rn RADON
7	87 (223) Fr FRANCIUM	88 (226) Ra RADIUM	89-103 Ac-Lr Actinide	104 (261) Rf RUTHERFORDIUM	105 (262) Db DUBNIUM	106 (266) Sg SEABORGIUM	107 (264) Bh BOHRIUM	108 (277) Hs HASSIUM	109 (268) Mt MEITNERIUM	110 (281) Uun UNUNNIUM	111 (272) Uuu UNUNUNIUM	112 (285) Uub UNUNBIUM	114 (289) Uuq UNUNQUADIUM					

LANTHANIDE

57 138.91 La LANTHANUM	58 140.12 Ce CERIUM	59 140.91 Pr PRASEODYMIUM	60 144.24 Nd NEODYMIUM	61 (145) Pm PROMETHIUM	62 150.36 Sm SAMARIUM	63 151.96 Eu EUROPIUM	64 157.25 Gd GADOLINIUM	65 158.93 Tb TERBIUM	66 162.50 Dy DYSPROSIUM	67 164.93 Ho HOLMIUM	68 167.26 Er ERBIUM	69 168.93 Tm THULIUM	70 173.04 Yb YTTERIUM	71 174.97 Lu LUTETIUM
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ACTINIDE

89 (227) Ac ACTINIUM	90 232.04 Th THORIUM	91 231.04 Pa PROTACTINIUM	92 238.03 U URANIUM	93 (237) Np NEPTUNIUM	94 (244) Pu PLUTONIUM	95 (243) Am AMERICIUM	96 (247) Cm CURIUM	97 (247) Bk BERKELIUM	98 (251) Cf CALIFORNIUM	99 (252) Es EINSTEINIUM	100 (257) Fm FERMIUM	101 (258) Md MENDELEVIUM	102 (259) No NOBELIUM	103 (262) Lr LAWRENCIUM
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(1) Pure Appl. Chem., 73, No. 4, 667-683 (2001)

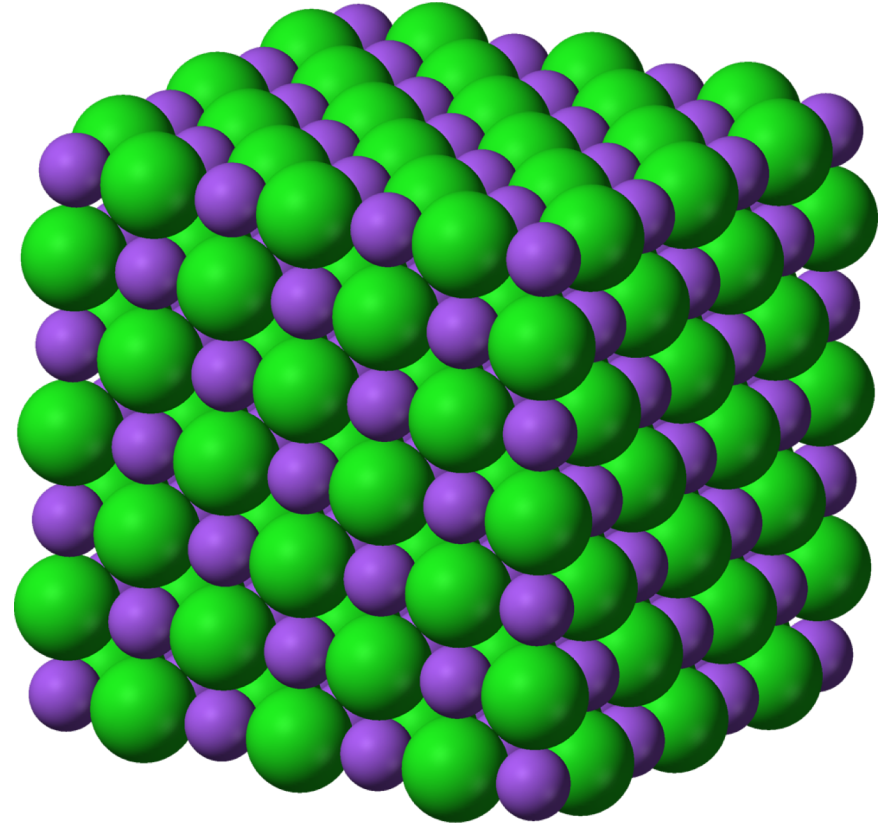
Relative atomic mass is shown with five significant figures. For elements having no stable nuclides, the value enclosed in brackets indicates the mass number of the longest-lived isotope of the element.

However three such elements (Th, Pa, and U) do have a characteristic terrestrial isotopic composition, and for these an atomic weight is tabulated.

Editor: Aditya Vardhan (adivar@netlinx.com)

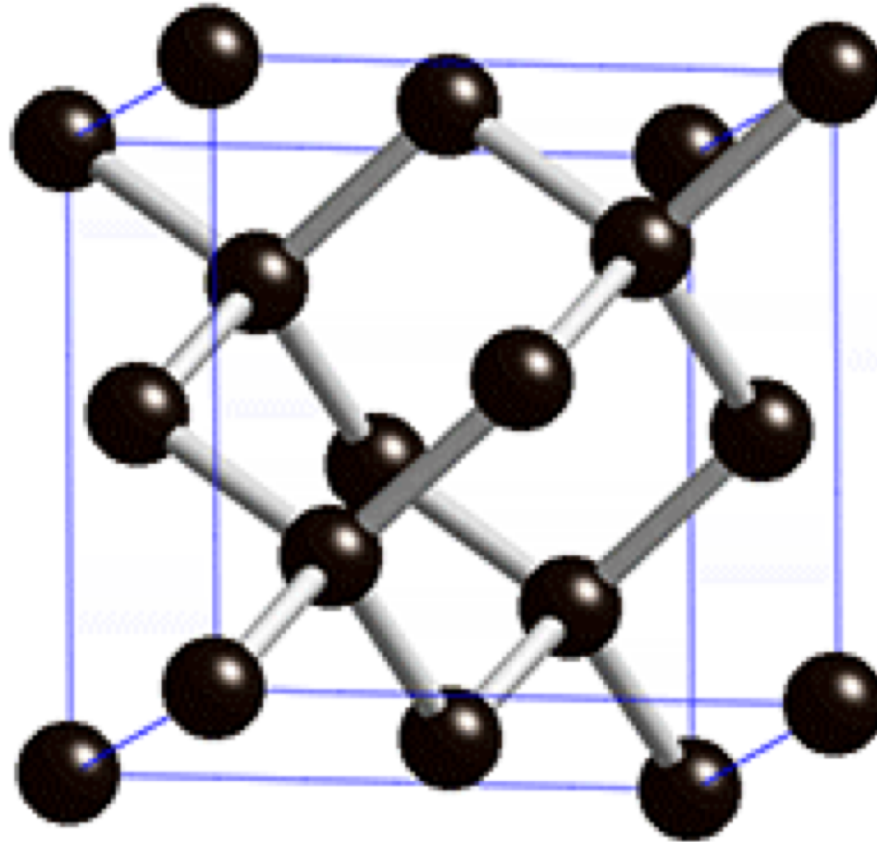
Crystal Lattice

- crystals: periodic arrangement of atoms, ions or molecules
- smallest group of atoms that repeats is unit cell
- unit cells repeat at lattice points
- crystal structure and symmetry determine many physical properties



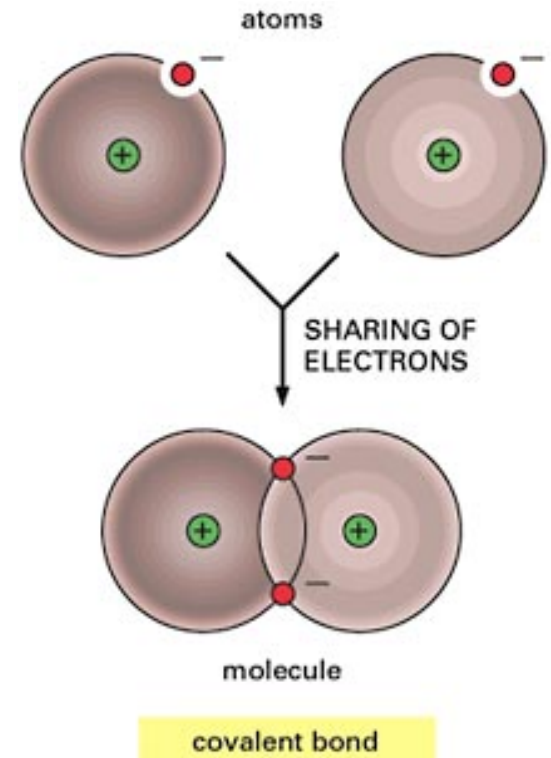
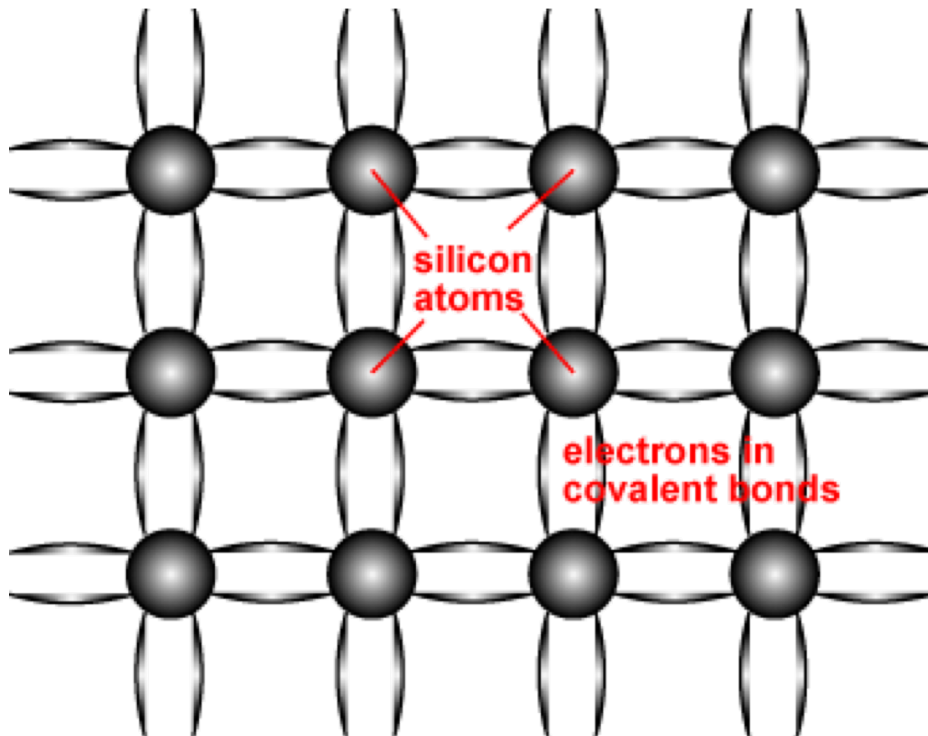
purple:Na⁺, green: Cl⁻

Diamond Unit Cell



Covalent Bond

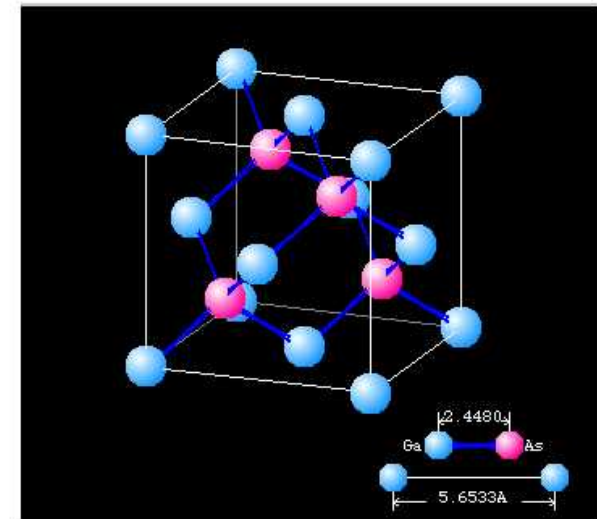
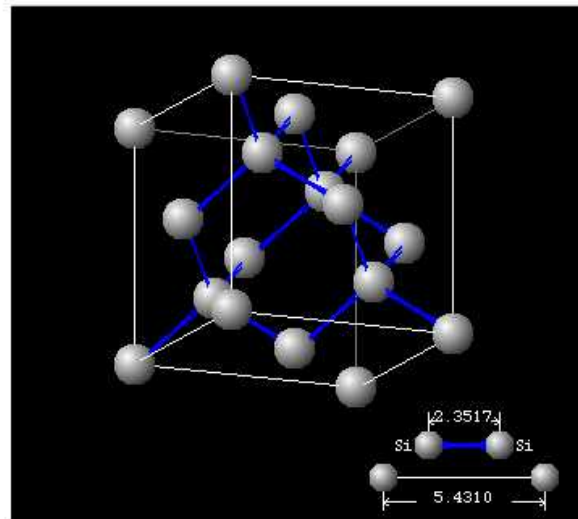
- Elements with 4 e^- in valence shell form crystals with **diamond lattice structure** (each atom bonds to four neighbors).
- Double-bonds between neighbours due to “shared” electrons



Diamond Lattice with 2 Elements

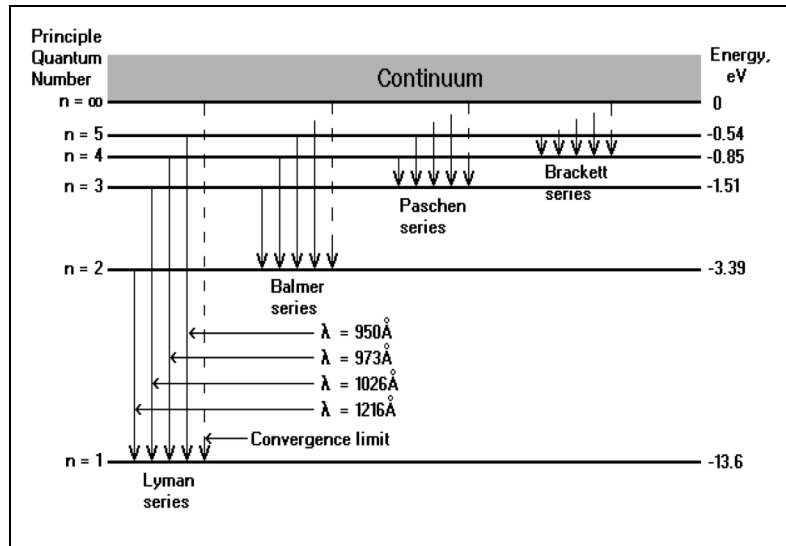
Diamond lattice not only formed by group IV elements (C, Si, Ge) but also by III-V semiconductors (InSb, GaAs, AlP)

	IIIA	IVA	VA	VIA
	5 B	6 C	7 N	8 O
	13 Al	14 Si	15 P	16 S
IIB	30 Zn	32 Ge	33 As	34 Se
	48 Cd	50 Sn	51 Sb	52 Te



Electronic States and Bands

Single (Hydrogen) Atom

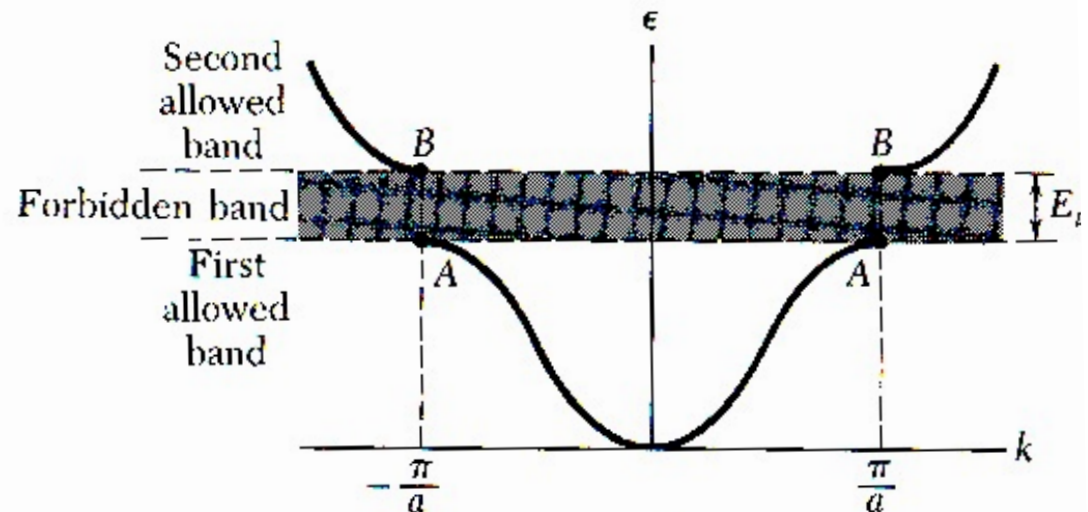
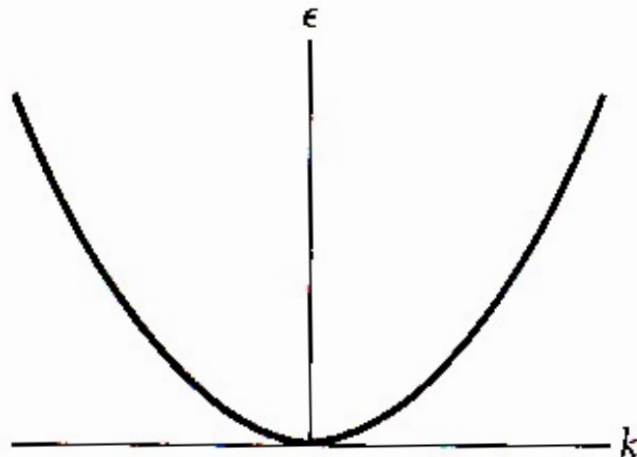


Atoms in crystal

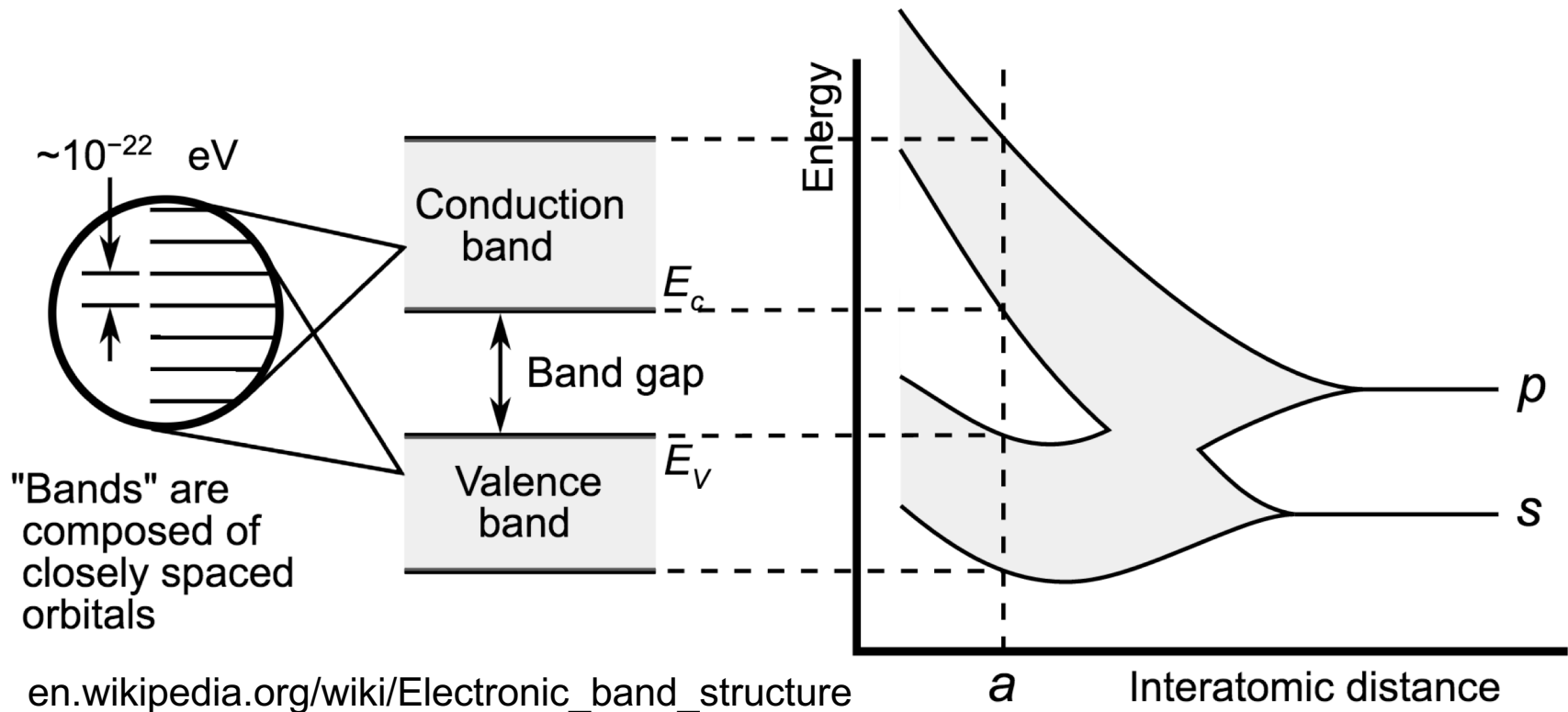
Wavefunctions Ψ overlap

→ Energy levels of individual atoms split due to Pauli principle (avoiding the same quantum states)

→ Multiple splitting → “bands”



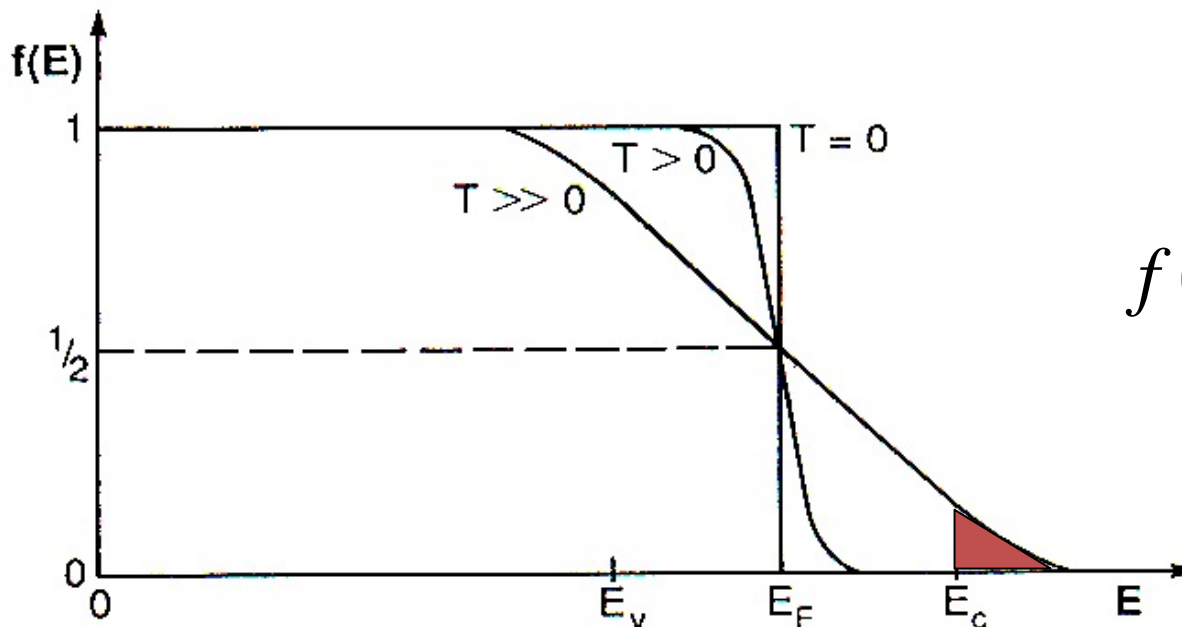
Electron Energy Levels in Carbon



- possible energy levels of electrons in diamond lattice
- Pauli exclusion principle leads to splitting of energy states
- electrons in conduction band can move freely

Fermi Energy

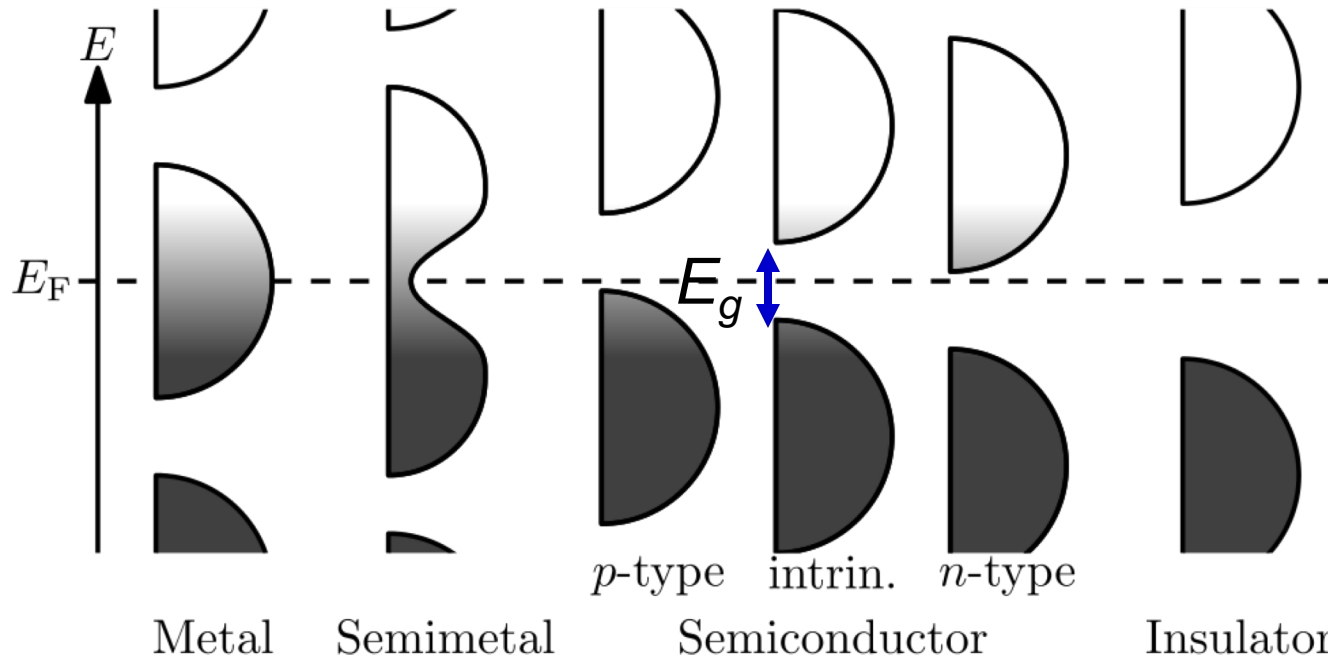
- **Pauli exclusion principle** 2 fermions cannot occupy same quantum state; fill up unoccupied quantum states
- **Fermi energy** E_F is energy of highest occupied quantum state in a system of fermions at $T = 0\text{K}$
- **Fermi function** $f(E)$ is probability that state of energy E is occupied at temperature T ; $f(E_F) = 0.5$



$$f(E) = \frac{1}{1 + e^{(E - E_F)/kT}}$$

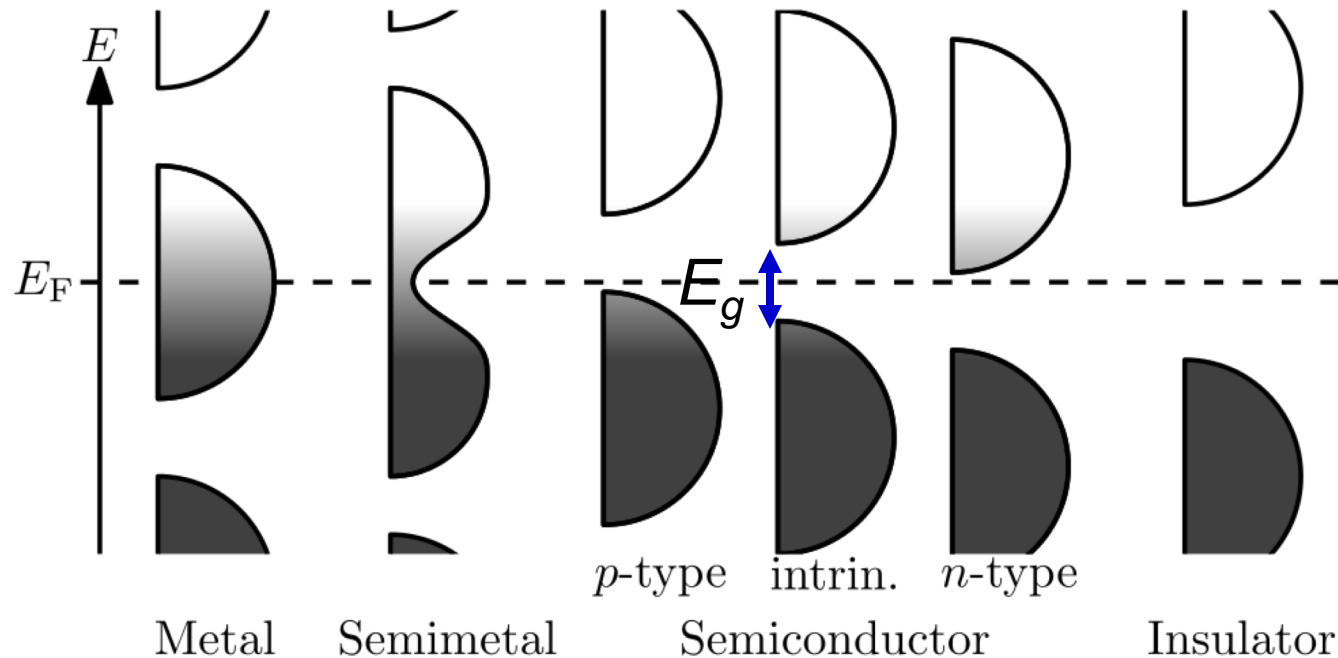
Electric Conductivity

Conductivity requires charge carriers in the conduction band



- Metal: Fermi energy in the middle of conduction band -> free electrons at all temperatures
- Insulator: large band gap and Fermi energy between bands
- Semiconductor: narrow band gap and Fermi energy between bands

Bandgap



Overcome bandgap E_g by lifting e^- into conduction band:

1. external excitation, e.g. via a photon ← photon detector
2. thermal excitation
3. impurities

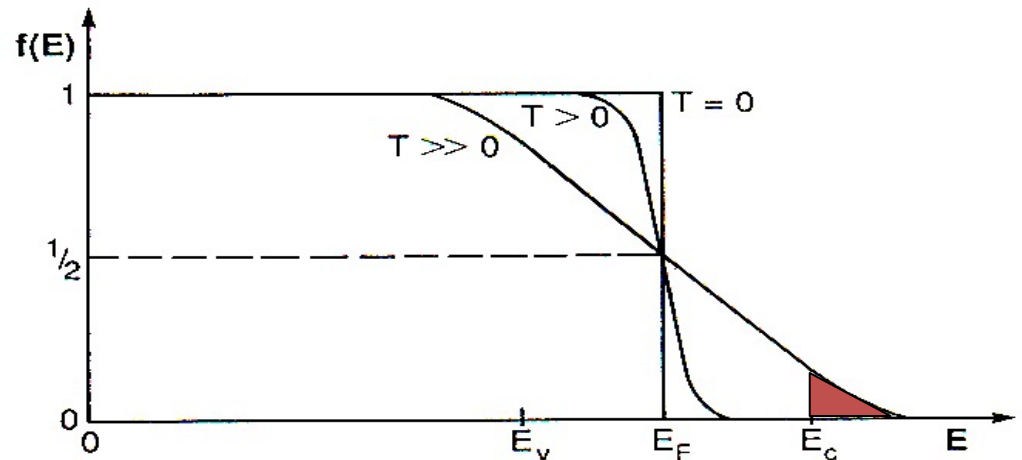
Electrons in Conduction Band

- Number of occupied states in conduction band is given by product of number of possible states N_c in conduction band times the probability $f(E_c)$ that they are occupied
- For silicon, temperature increase of 8K doubles number of electrons in conduction band

$$n_0 = N_c f(E_c)$$

$$N_c = 2 \left(\frac{2 m_{eff} kT}{h^2} \right)^{3/2}$$

$$f(E_c) = \frac{1}{1 + e^{(E_c - E_F)/kT}} \approx e^{-(E_c - E_F)/kT} \quad E_c - E_F \gg kT$$



Intrinsic Photo-Conductors: Basic Principle

- semi-conductor: few charge carriers \rightarrow high resistance
- charge carriers = electron-hole pairs
- photon lifts e^- into conduction band
- applied electric field drives charges to electrodes

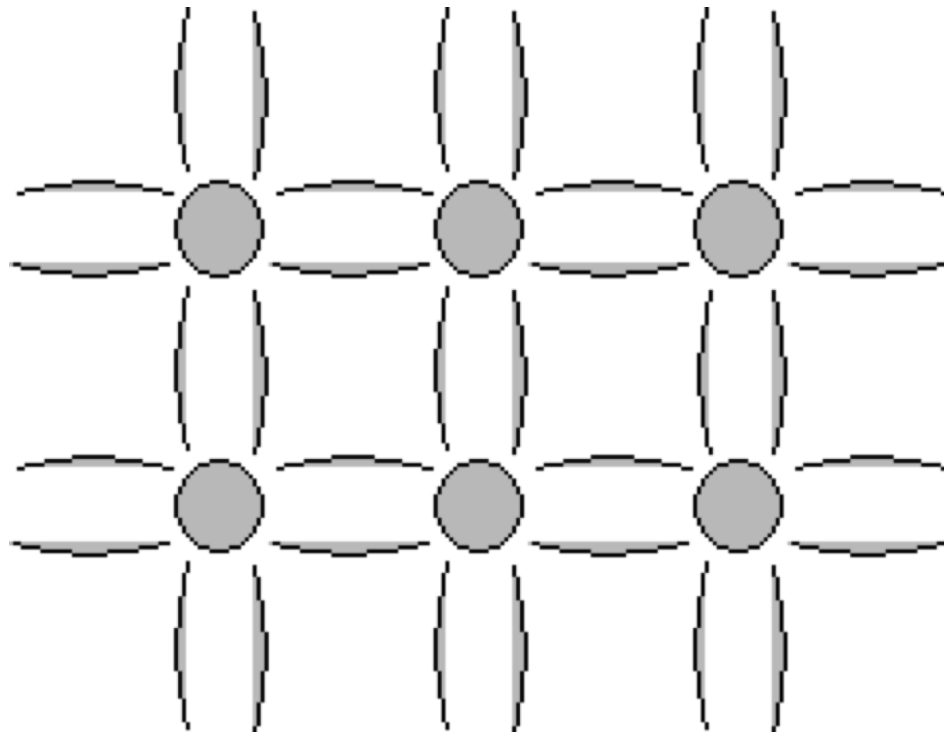


Photo-Current

- Conductivity: $j = \sigma E$
- Current: $I = jwd$
- $V = RI$, $E = V/l$
- $\sigma = j/E = jl/V = jl/(RI)$
 $= jl/(Rjwd)$
 $= 1/R \cdot l/wd$

$$\sigma = \frac{1}{R_d} \frac{l}{wd} = qn_0\mu_n$$

where:

R_d = resistance

w, d, l = geometric dimensions

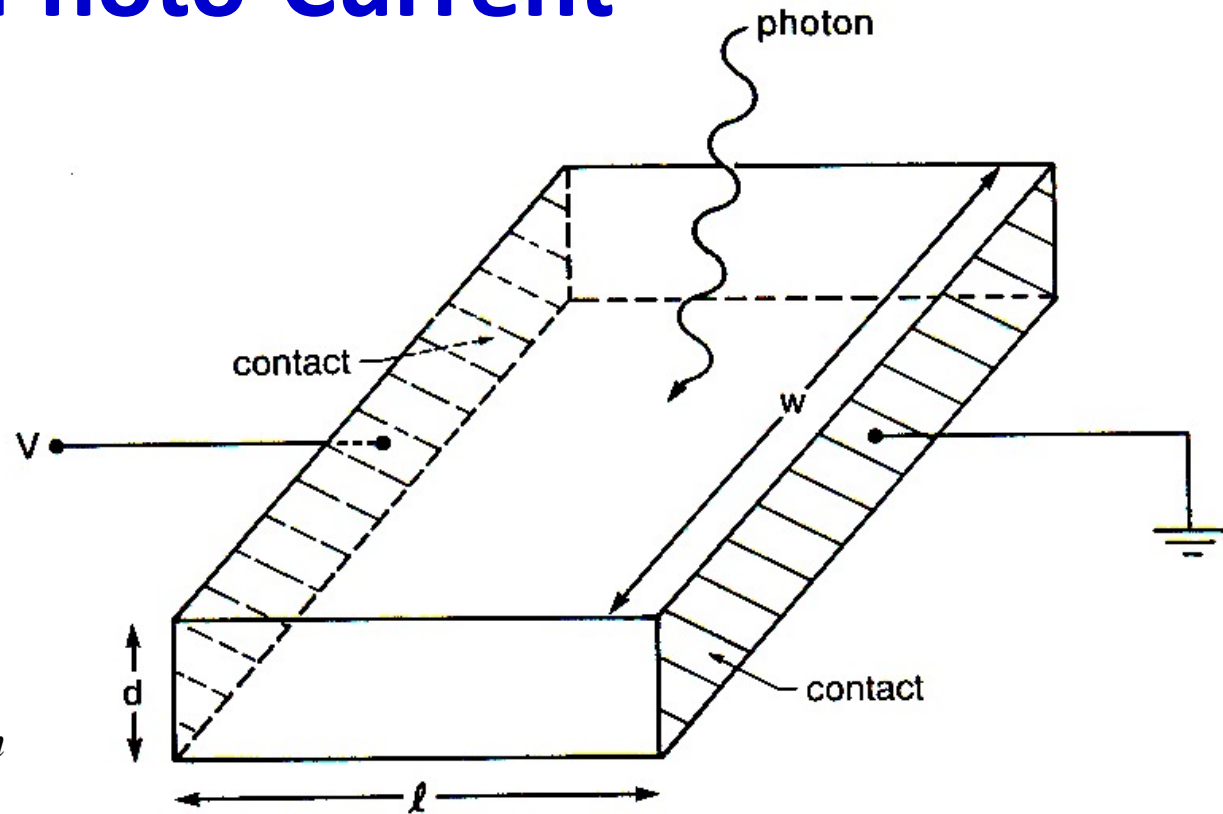


Photo-Current

$$\sigma = \frac{1}{R_d} \frac{l}{wd} = qn_0\mu_n$$

where:

R_d = resistance

w, d, l = geo. dimensions

q = elementary charge

n_0 = number density of
charge carriers

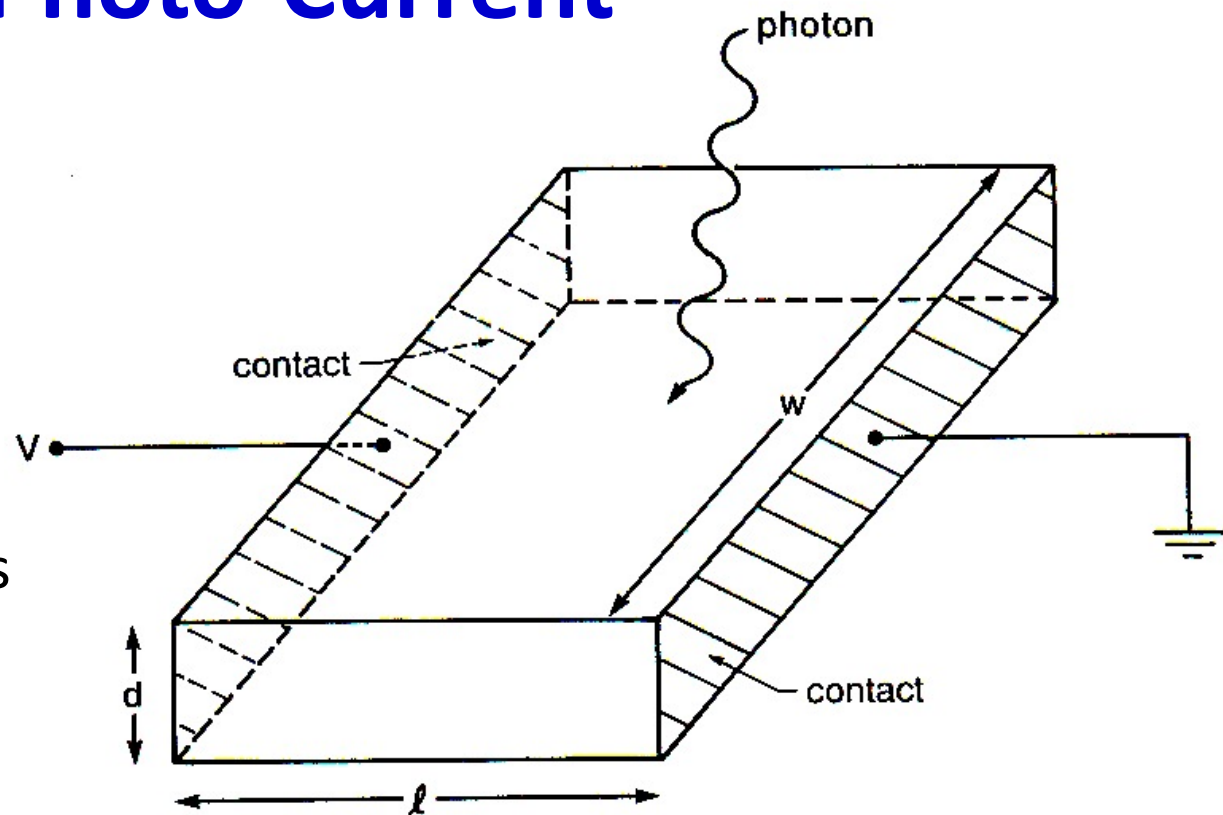
φ = photon flux

η = quantum efficiency

τ = mean lifetime before recombination

μ_n = electron mobility; drift velocity $v = \mu_n E$, current density

$j = n_0 q v$, $\sigma = j/E = n_0 q \mu_n E/E = q n_0 \mu_n$



$$n_0 = \frac{\varphi \eta \tau}{wdl}$$

Important Quantities and Definitions

Quantum efficiency η = $\frac{\text{\# absorbed photons}}{\text{\# incoming photons}}$

Responsivity S = $\frac{\text{electrical output signal}}{\text{input photon power}}$

Wavelength cutoff: $\lambda_c = \frac{hc}{E_g} = \frac{1.24 \mu\text{m}}{E_g [\text{eV}]}$

Photo-current: $I_{ph} = q\phi\eta G$

Photoconductive gain G : $G = \frac{I_{ph}}{q\phi\eta} = \frac{\tau}{\tau_t} = \frac{\text{carrier lifetime}}{\text{transit time}}$

The **product ηG** describes the probability that an incoming photon will produce an electric charge that will reach an electrode

Limitations of Intrinsic Semiconductors

- long-wavelength cutoffs

$$\lambda_c = \frac{hc}{E_g}$$

Germanium: 1.85 μm

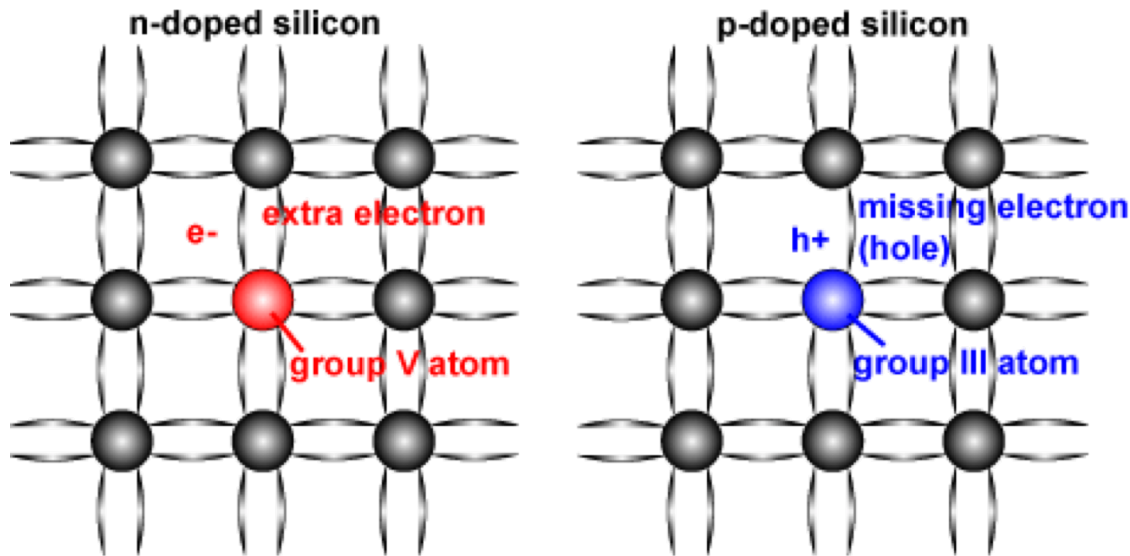
Silicon: 1.12 μm

GaAs: 0.87 μm

- difficult to create completely pure material
- problems to make good electrical contacts to pure Si
- difficult to avoid impurities and minimize thermal noise

Extrinsic Semiconductors

- **extrinsic semiconductors:**
charge carriers = electrons (n-type) or holes (p-type)
- addition of impurities at low concentration to provide excess electrons or holes
- much **reduced bandgap** -> longer wavelength cutoff



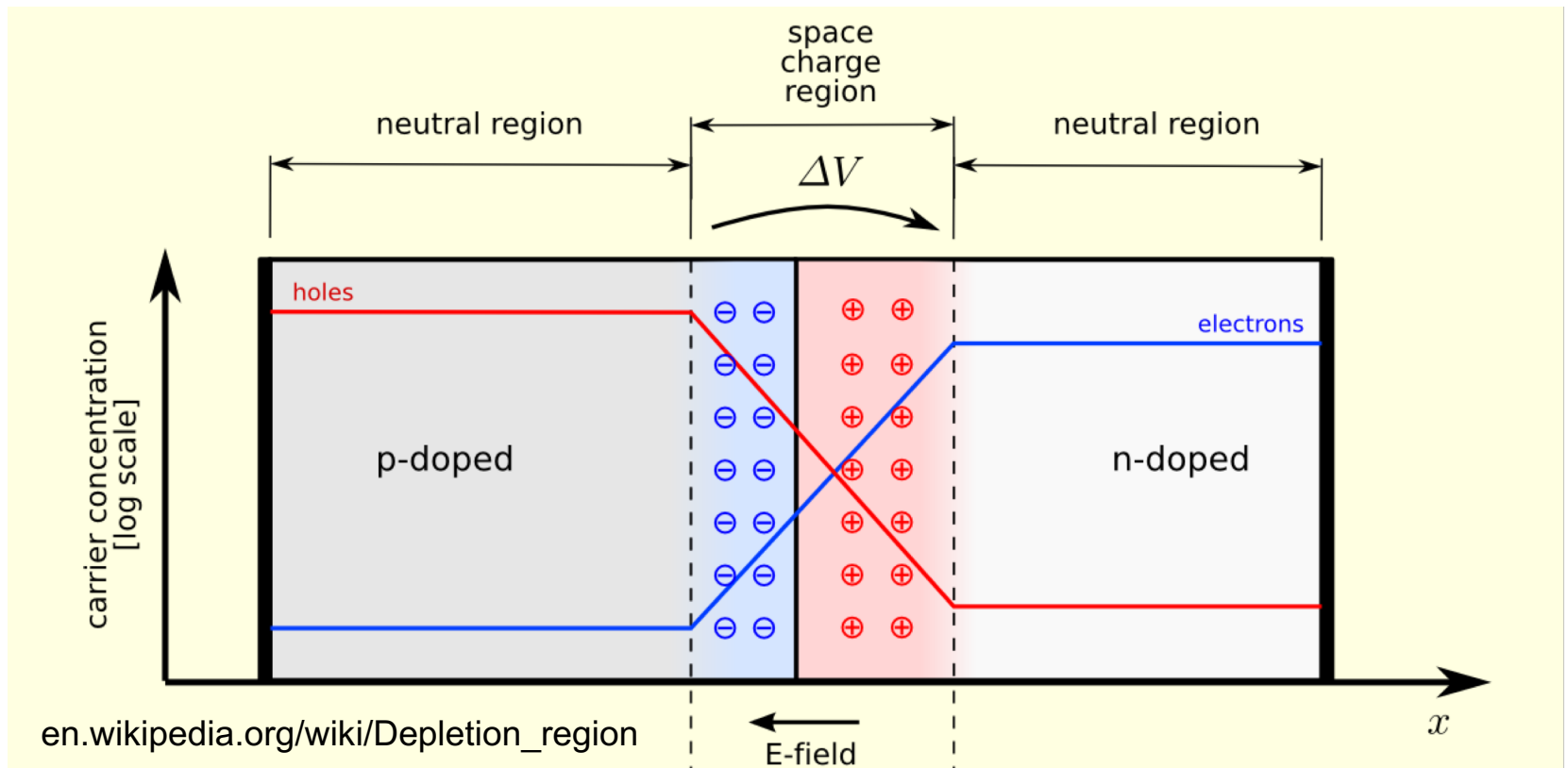
Example: addition of boron to silicon in the ratio 1:100,000 increases its conductivity by a factor of 1000!

Extrinsic Semiconductor Band Gaps

Impurity	Type	Ge	Si
		Cutoff wavelength λ_c (μm)	Cutoff wavelength λ_c (μm)
Al	p		18.5 ^a
B	p	119 ^b	28 ^a
Be	p	52 ^b	8.3 ^a
Ga	p	115 ^b	17.2 ^a
In	p	111 ^b	7.9 ^a
As	n	98 ^b	23 ^a
Cu	p	31 ^b	5.2 ^a
P	n	103 ^b	27 ^a
Sb	n	129 ^b	29 ^a

Problem: absorption coefficients much less than for intrinsic photoconductors → low quantum efficiency → active volumes of pixels must be large

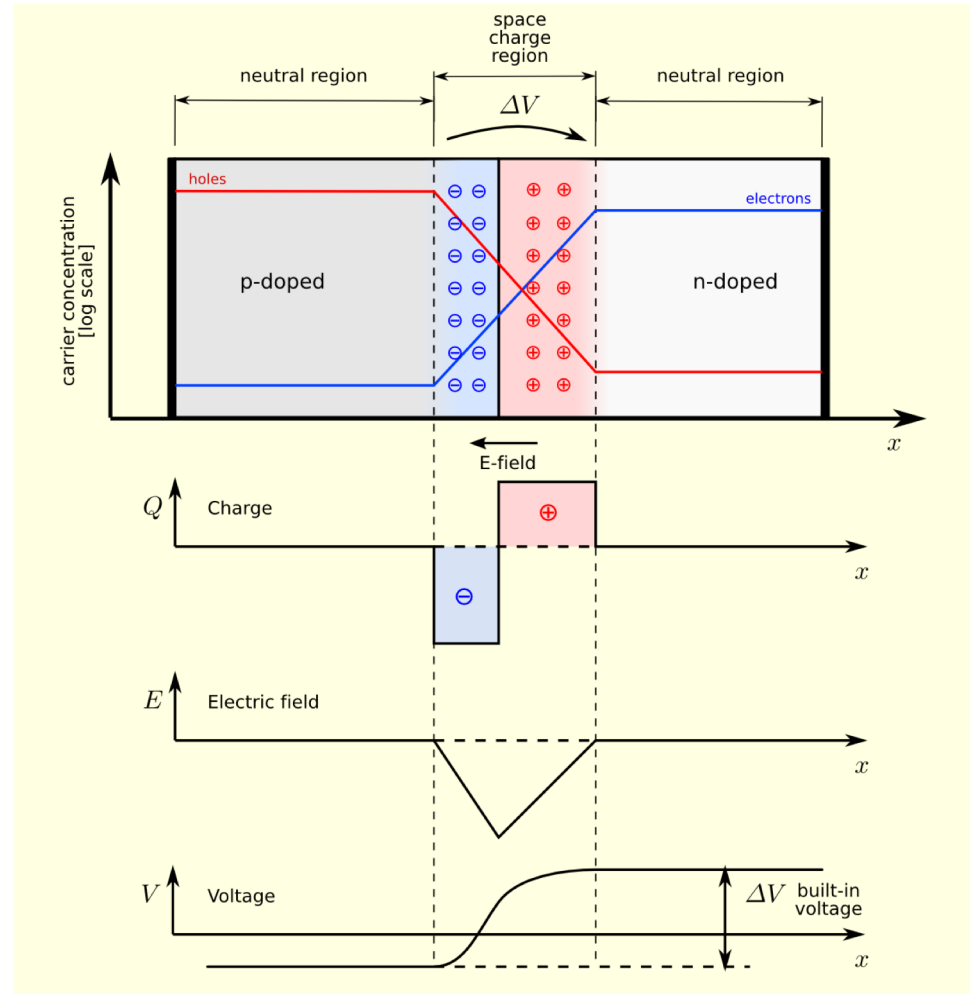
Depletion Zone / PN Junction



- junction between p- and n-doped Si (both are electrically neutral)
- e^- migrate to P-side, holes migrate to N-side
- e^- can only flow over large distances in n-type material, holes can only flow in p-type material

Depletion Zone / PN Junction

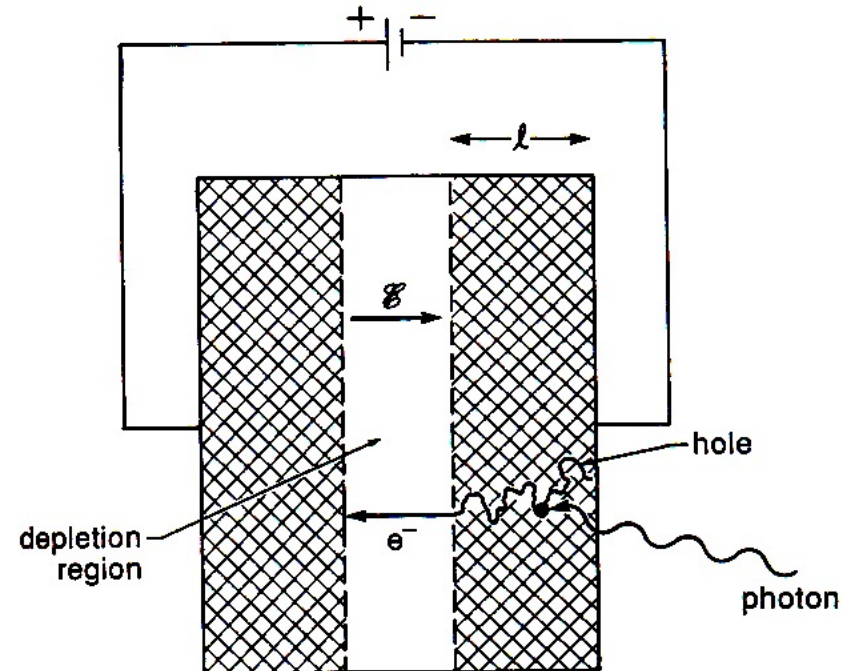
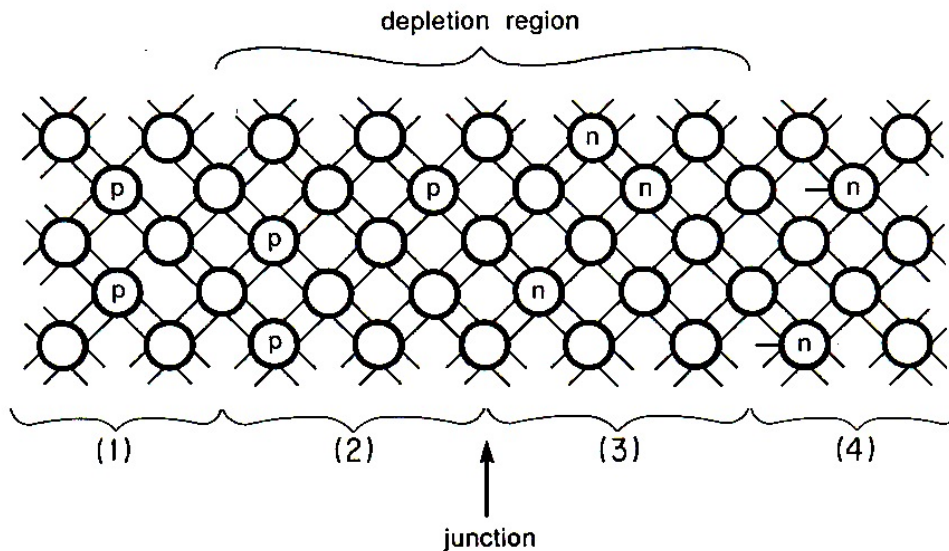
- migrating e^- from N-side to P-side produces positive donor ion on N-side; migrating hole produces negative acceptor ion on P-side
- migrating e^- recombine with holes on P-side; migrating holes recombine with e^- on N-side
- migrating e^- and holes, mobile charge carriers are depleted
- charged ions remain adjacent to interface



en.wikipedia.org/wiki/Depletion_region

Photodiodes

- junction between *two* oppositely doped zones
- 2 adjacent zones create a depletion region

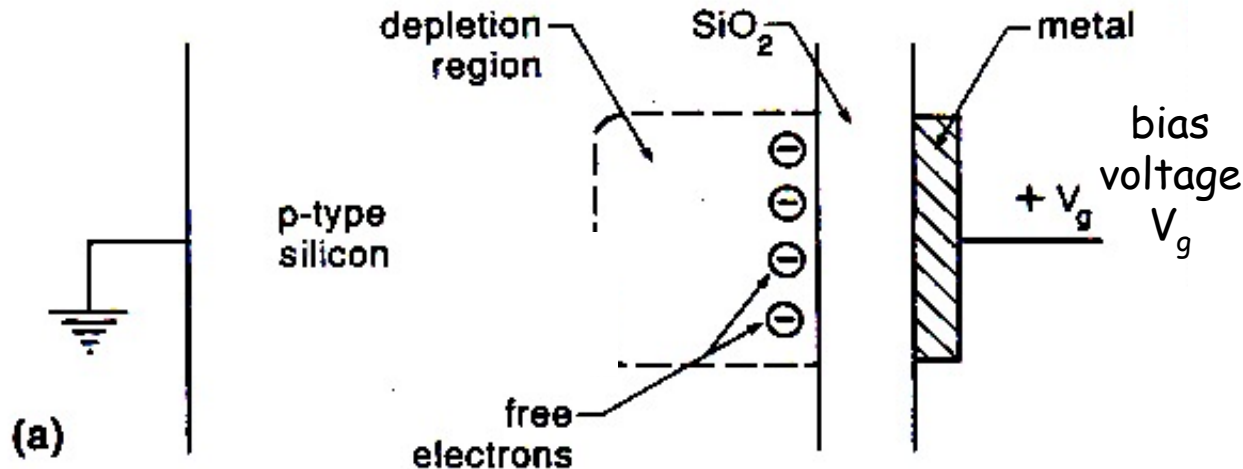


1. Photon gets absorbed e.g. in the p-type part
2. Absorption creates an e^- -hole pair
3. The e^- diffuses through the material
4. Voltage drives the e^- across the depletion region → photo-current

Charge Coupled Devices (CCDs)

CCDs = array of integrating capacitors.

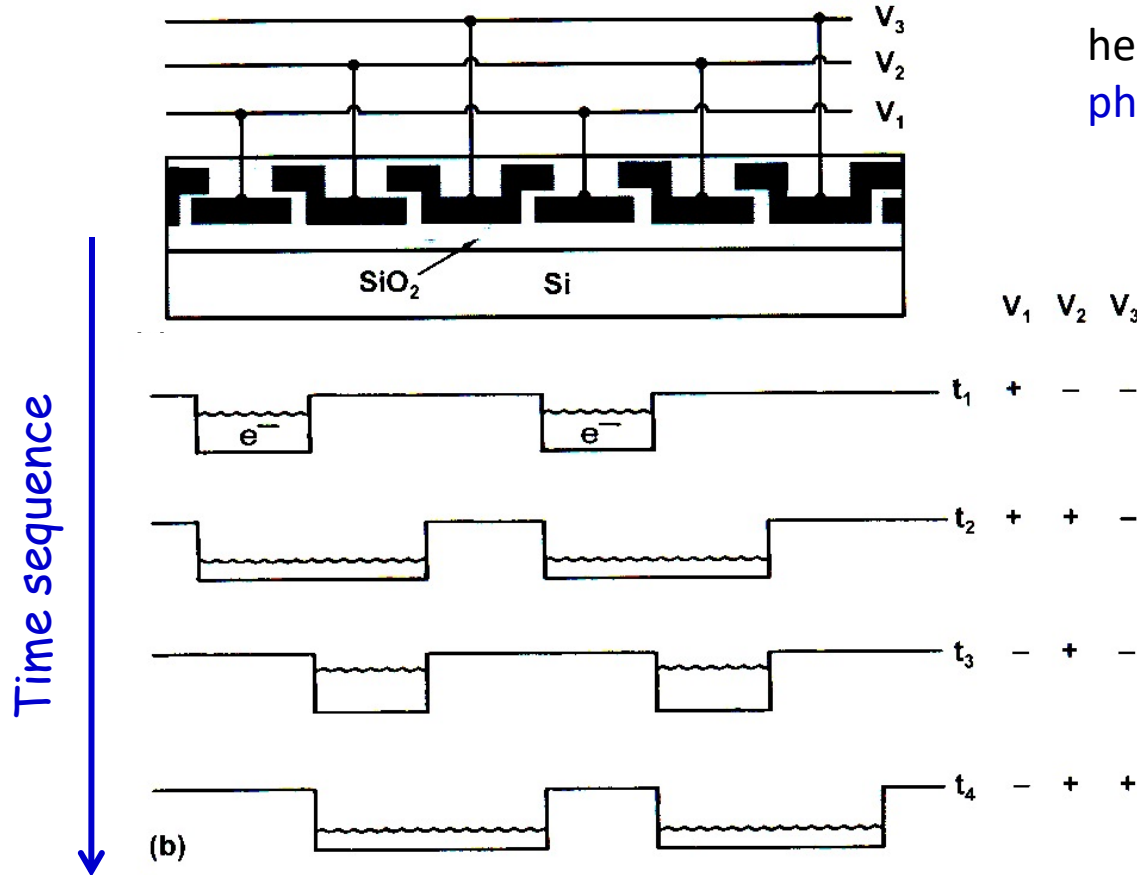
Pixel structure: metal “gate” evaporated onto SiO_2 (isolator) on silicon
= MOS



1. photons create free e^- in the photoconductor
2. e^- drift toward the electrode but cannot penetrate the SiO_2 layer
3. e^- accumulate at the Si— SiO_2 interface
4. total **charge collected at interface measures number of photons** during the exposure
5. \rightarrow read out the number of e^-

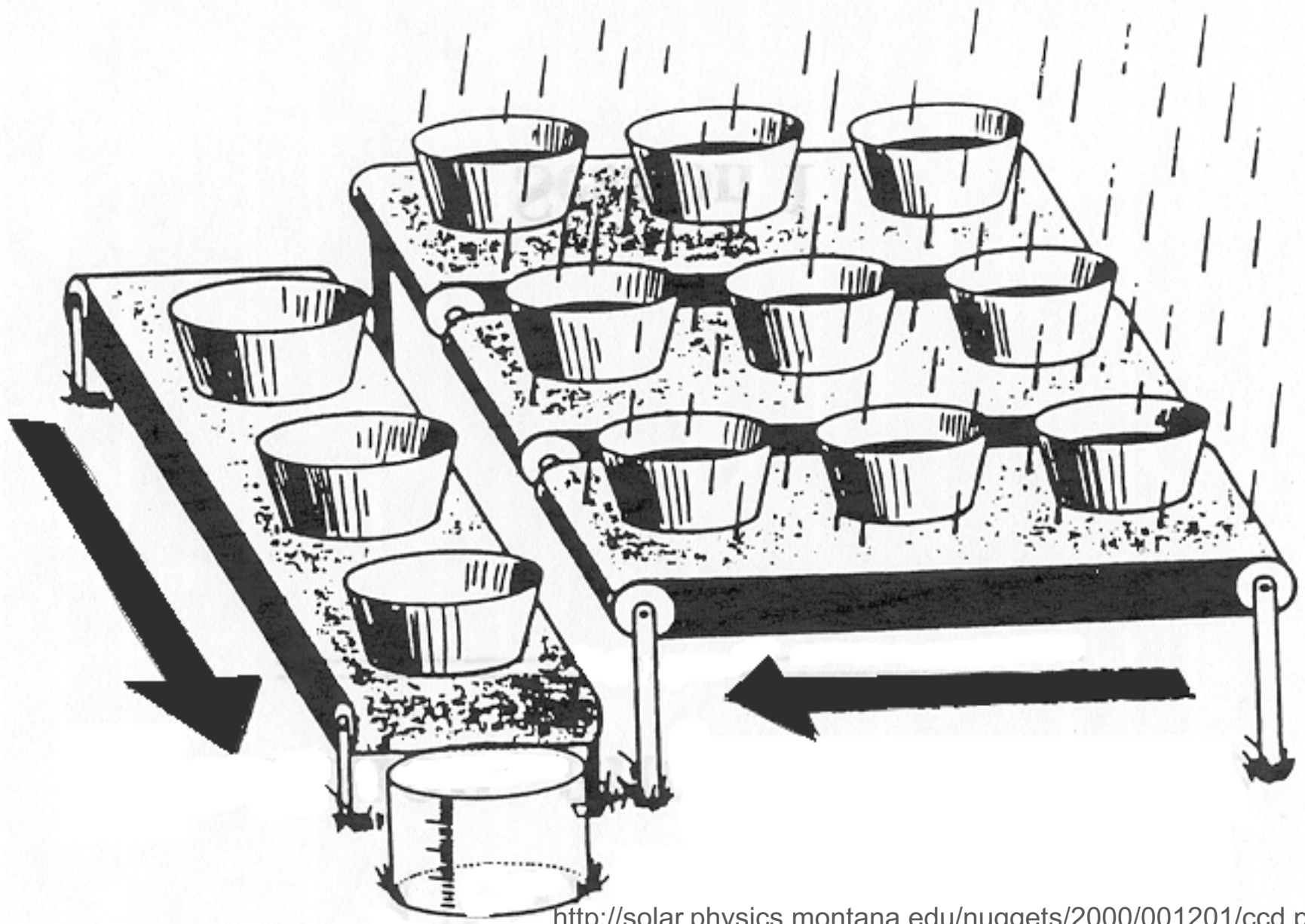
Charge Coupled Readouts

Charges are moved along columns to the edge of the array to the output amplifier



here: 3 sets of electrodes \rightarrow 3-phase CCD

Charge transfer (in-)efficiencies (CTEs) due to electrostatic repulsion, thermal diffusion and fringing fields



<http://solar.physics.montana.edu/nuggets/2000/001201/ccd.png>

Charge Transfer Efficiency (CTE)

Time-dependent mechanisms that influence the CTE:

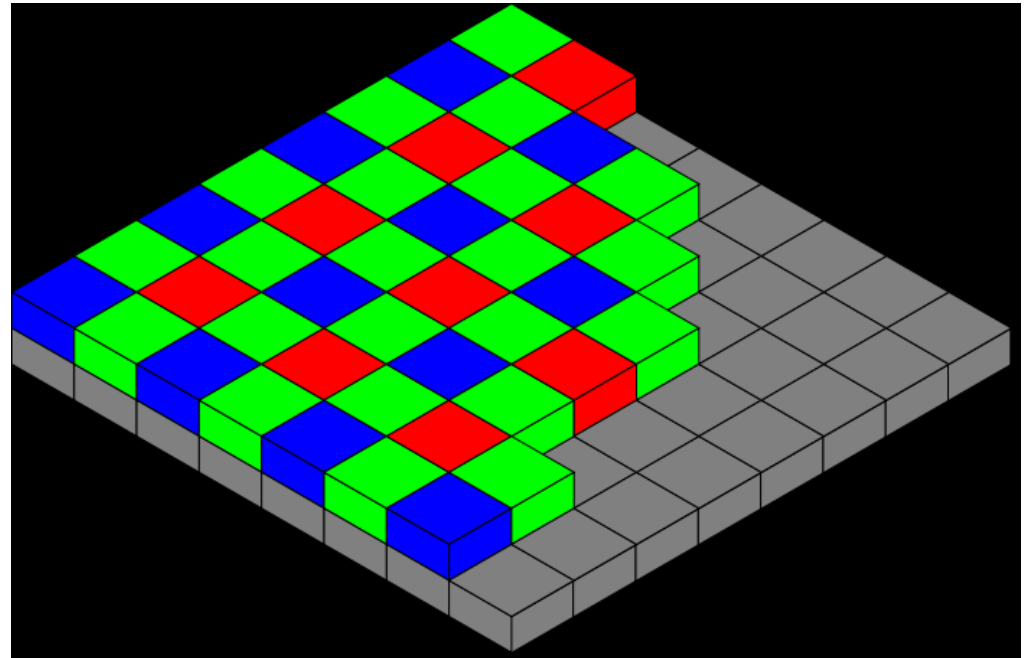
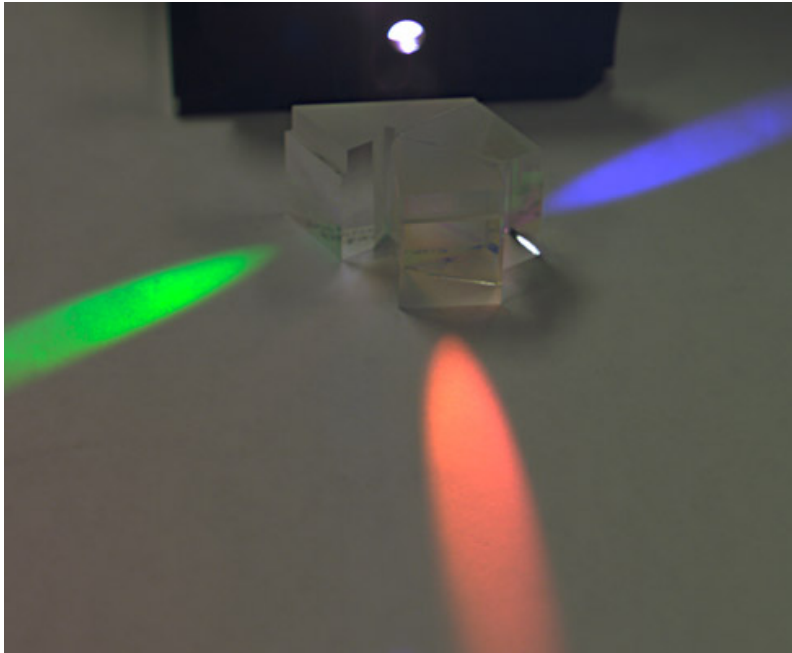
1. **Electrostatic repulsion** causes electrons to drift to the neighbouring electrode with time constant for charge transfer τ_{sl} .
2. **Thermal diffusion** drives electrons across the storage well at τ_{th} .
3. “**Fringing fields**” due to dependency of the well on the voltages of neighbouring electrodes (τ_{ff}).

Approximation for the CTE of a CCD with m phases: $CTE = \left(1 - e^{-t/\tau}\right)^m$

Noise from **charge transfer inefficiency**: $\varepsilon = (1-CTE)$

CCD Color Sensors

1. Three exposures through 3 filters – only works for fixed targets
2. Split input into 3 channels with separate filter and CCD
3. Bayer mask over CCD – each subset of 4 pixels has one filtered red, one blue, and two green



Main Detector Noise Components

G-R noise $\langle I_{G-R}^2 \rangle = 4q^2 \phi \eta G^2 \Delta f$

Fundamental **statistical noise due to the Poisson statistics** of the photon arrival → transferred into the statistics of the **g**enerated and **r**ecombined holes and electrons

Johnson or kTC noise $\langle I_J^2 \rangle = \frac{4kT}{R} \Delta f$

Fundamental **thermodynamic noise** due to thermal motion of charge carriers.
Photo-conductor is an RC circuit where $\langle Q^2 \rangle = kTC$

1/f noise $\langle I_{1/f}^2 \rangle \propto \frac{I^2}{f} \Delta f$

increased **noise at low frequencies**, due to bad electrical contacts, temperature fluctuations, surface effects (damage), crystal defects, and JFETs, ...

Total noise: $\langle I_N^2 \rangle = \langle I_{G-R}^2 \rangle + \langle I_J^2 \rangle + \langle I_{1/f}^2 \rangle$

BLIP and NEP

Operationally, background-limited performance (BLIP) is always preferred:

$$\langle I_{G-R}^2 \rangle \gg \langle I_J^2 \rangle + \langle I_{1/f}^2 \rangle$$

The noise equivalent power (NEP) is the signal power that yields an RMS S/N of unity in a system of $\Delta f = 1$ Hz:

$$NEP_{G-R} = \frac{2hc}{\lambda} \left(\frac{\varphi}{\eta} \right)^{1/2}$$

In BLIP the NEP can only be improved by increasing the quantum efficiency η as background photon noise dominates